# High-Resolution ARRAY ICP OES PlasmaQuant® PQ 9000



## PlasmaQuant® PQ 9000

Compact High-Resolution ARRAY optical emission spectrometer with an inductively coupled plasma for multi-element analyses equipped with a high-resolution echelle optical bench, fully PC controlled and an optional autosampler.

#### **High-Resolution Optics**

Optical bench is mounted on a rigid and compact base plate for high robustness and durability     Encapsulated and argon purged optical bench that eliminates air, dust particles and moisture from the entire optical path High-Resolution Echelle Double Monochromator with order preselection and minimal intensity losses to scattered light     Pre-monochromator with quartz prism     The optical bench does not require any thermostatting  Wavelength range  160 - 900 nm  Spectral resolution  Dual View PLUS  Dual View PLUS Plasma observation for 2+2 plasma views     Automated attenuation of axial and radial plasma views in one method  Peltier cooled CCD array detector with high quantum efficiency, increased UV-sensitivity and reduced warm-up times		
Spectral resolution       0.002 nm at 200 nm         Dual View PLUS       Plasma observation for 2+2 plasma views         Automated attenuation of axial and radial plasma views       Fast switching between axial and radial plasma views in one method         Peltier cooled CCD array detector with high quantum efficiency, increased UV-sensitivity and reduced warm-up	HR spectrometer	<ul> <li>for high robustness and durability</li> <li>Encapsulated and argon purged optical bench that eliminates air, dust particles and moisture from the entire optical path</li> <li>High-Resolution Echelle Double Monochromator with order preselection and minimal intensity losses to scattered light</li> <li>Pre-monochromator with quartz prism</li> </ul>
<ul> <li>Dual View PLUS</li> <li>Dual View PLUS Plasma observation for 2+2 plasma views</li> <li>Automated attenuation of axial and radial plasma views in one method</li> <li>Peltier cooled CCD array detector with high quantum efficiency, increased UV-sensitivity and reduced warm-up</li> </ul>	Wavelength range	160 - 900 nm
<ul> <li>Automated attenuation of axial and radial plasma views         <ul> <li>Fast switching between axial and radial plasma views in one method</li> </ul> </li> <li>Peltier cooled CCD array detector with high quantum efficiency, increased UV-sensitivity and reduced warm-up</li> </ul>	Spectral resolution	0.002 nm at 200 nm
Detector efficiency, increased UV-sensitivity and reduced warm-up	Dual View PLUS	<ul> <li>Automated attenuation of axial and radial plasma views</li> <li>Fast switching between axial and radial plasma views in one</li> </ul>
	Detector	efficiency, increased UV-sensitivity and reduced warm-up

#### **V Shuttle Torch**

Easily accessible and clearly laid out sampling system with V Shuttle Torch realizing short distances between sample and plasma for significantly reduced delay times

Spray chamber	<ul> <li>Optional for the use with hydrofluoric acid, with cooling of spray chamber or desolvation</li> </ul>
Nebulizer	<ul> <li>Range of concentric nebulizer with EasyFit® for quick interchange</li> <li>Optional for high salt contents, low gas flows and for the use of hydrofluoric acid</li> </ul>
Torch	<ul> <li>Firm and sliding torch base made from thermally and chemically resistant materials</li> <li>Built-in gas connections for high safety, precision and durability</li> </ul>
Plasma geometry	<ul> <li>Vertical plasma geometry for improved tolerance of complex matrices and high sample loads (e.g. petrochemical, saline or metallic materials).</li> <li>Deposit-free vertical torch avoids clogging and soot formation</li> <li>Best accuracy (RSD), blank values and range of samples to be analyzed without sample-pretreatment</li> </ul>



V Shuttle Torch	
Peristaltic pump	<ul> <li>12-roller peristaltic pump with adjustable contact pressure for uniform sample introduction</li> <li>4 tubing channels for maximum flexibility</li> </ul>
Gas control	<ul> <li>Fully automated gasbox with individual Mass Flow</li> <li>Controllers (MFC) for plasma, auxiliary and nebulizer gases</li> <li>MFC for the precise and safe addition of oxygen</li> </ul>

### **High-Frequency Generator**

- Free-running 40 MHz generator with solid state power supply for long-term plasma stability and for excellent reproducibility
- Incremental power variation between 700 and 1700 W for increased applicability
- Cooled four-winding induction coil for efficient energy transfer to the plasma independent of sample load or matrix

#### **Accessories**

#### Autosampler

- High through-put xyz- autosampler
- Up to 3 sample trays for sample container of different volume

Additional technical data		
Dimensions	987 mm x 937 mm x 765 mm (W x H x D)	
Weight	170 kg	
Environmental requirements	<ul> <li>Temperature +15 °C up to 35 °C</li> <li>Relative Humidity 20 - 90 % at +30 °C</li> </ul>	
Power requirements	230 V (±10 %); 50/60 Hz, slow fuse 35 A 4600 VA	